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Eprints ID: 3861

To link to this article: doi.org/10.1149/1.3207589
URL: <http://dx.doi.org/10.1149/1.3207589>

To cite this version: N. Gleizes, Alain and Krisyuk, V. V. and Aloui, Lyacine and Turgambaeva, A. and Sarapata, Bartosz and Prud'homme, N. and Senocq, François and Samélor, D. and Zielinska-Lipiec, Anna and Dumestre, Frédéric and Vahlas, Constantin (2009) *Iron amidinates as precursors for the MOCVD of iron-containing thin films*. ECS Transactions, vol. 25 (n° 8). pp. 181-188. ISSN 1938-6737

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Iron amidinates as precursors for the MOCVD of iron-containing thin films

Alain N. Gleizes¹, Vladislav Krisyuk^{1,2}, Lyacine Aloui¹, Asiya Turgambaeva^{1,2}, Bartosz Sarapata^{1,3}, Nathalie Prud'Homme¹, François Senocq¹, Diane Samélor¹, Anna Zielinska-Lipiec³, Frédéric Dumestre⁴ and Constantin Vahlas*

¹ CIRIMAT, ENSIACET, 118 Route de Narbonne, 31077 Toulouse cedex 4, France. E-mail: constantin.vahlas@ensiacet.fr, phone: +33 562 885 670, fax: +33 562 885 600

² Nikolaev Institute of Inorganic Chemistry SB RAS ; Ave. Lavrentiev, 3, Novosibirsk, 630090, Russia. E-mail: vladislav.krisyuk@ensiacet.fr

³ AGH University of Science and Technology (AGH-UST), Al. Mickiewicza 30, PL-30 059 Krakow, Poland. E-mail : sarapata@agh.edu.pl

⁴ NanoMePS ; Département de Genie Physique, INSA, 135 Avenue de Rangueil, 31077 Toulouse Cedex 4, France. E-mail : contact@nanomeps.fr

Within the framework of an ongoing project, we are currently investigating the co-deposition of bimetallic and trimetallic films by MOCVD within the Al-Cu-Fe system. This intermetallic system can be a base for preparing complex metallic alloys (CMA) having unique combinations of properties.¹ The component metals of the Al-Cu-Fe system have differing chemical properties and the choice of the right precursors is not just finding metal complexes with similar volatilities and similar decomposition temperatures. First of all, the highly electropositive character of aluminium excludes the presence of highly electronegative elements such as oxygen and halogens. The present report deals with non oxygenated iron precursors. A wide range of precursors has already been tested for MOCVD of iron, but an optimal iron compound for practical MOCVD of pure iron films is missing. Besides, the affinity of iron for carbon facilitates the formation of carbides. This is the first reported study of iron amidinates tentatively used as precursors for MOCVD of iron. Iron amidinates were chosen because they contain no oxygen atoms and no Fe-C bonds. We report here on the investigation of two iron amidinates: dinuclear² iron bis(*N,N'*-diisopropylacetamidinate) ($(\text{Fe}_2(\mu^2\text{-Pr-MeAMD})_2(\eta^2\text{-Pr-MeAMD})_2)$ (**1**), and mononuclear² iron bis(*N,N'*-di-*tert*-butylacetamidinate) ($(\text{Fe}(\text{Bu-MeAMD})_2)$ (**2**). Mass spectrometry showed them to be mononuclear in the gas phase. Depositions were made on polycrystalline copper discs in the temperature ranges of 350-450°C with **1** and 280-350°C with **2**. Deposited films were analyzed and characterized by electron probe microanalysis (EPMA), X-ray photoelectron spectroscopy (XPS), grazing incidence X-ray diffraction (GIXRD) and scanning electron microscopy (SEM). They contain Fe and/or Fe₃C. The films prepared from **1** contain Fe₄C also. Those prepared from **2** contain Fe₄C or Fe₄N, depending on the temperature and the ratio between precursor and H₂ flows. The isopropyl derivative proved to release more carbonaceous deposits (Table 1). The mechanism of Fe₄N formation from **2** was deduced from mass spectrometry analysis. The films deposited on well polished copper present a grey, mirror-like metallic surface. This morphology is more pronounced

for films processed from precursor **2**. When deposited at temperature below 300°C, the films are made of densely packed nanocrystallites (size < 100 nm), independently of the precursor. The film prepared from **2** at 350°C (Fig. 1) is well crystallized and shows the <111> texture of Fe₄N evidenced by the XRD pattern.

This work may be considered as a screening approach for the use of iron amidinates as precursors for preparing iron-based materials by the MOCVD technique. Further studies should investigate the influence of reactive atmospheres. Besides Fe, the two isomeric compounds Fe₄N and Fe₄C are interesting materials for numerous applications, provided appropriate operating conditions are identified in dedicated CVD processes to produce them in the pure state. Fe₄N presents chemically inert and mechanically hard surfaces and interesting magnetic properties. Moreover, for the purpose of the present work, Fe₄N is thermally unstable and decomposes producing pure iron.

References

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Table 1. Carbon and nitrogen contents, and identified phases of the films, determined by EPMA and XRD, respectively. Parentheses correspond to phases, which have not been unambiguously identified. The sample code shows the precursor (1 or 2), the reactor (A or B) and the temperature of deposition in °C.

| Code | Precursor | T _{deposition} (°C) | % at C | % at N | Identified phases |
|-------|-----------|------------------------------|--------|--------|--------------------------------------------|
| 1A350 | 1 | 350 | 24 | 0 | (Fe), Fe ₃ C |
| 1A400 | 1 | 400 | 28 | 0 | Fe, Fe ₃ C, Fe ₄ C |
| 1A450 | 1 | 450 | 33 | 0 | (Fe), Fe ₃ C, Fe ₄ C |
| 2A280 | 2 | 280 | 18 | 0 | (Fe, Fe ₃ C), Fe ₄ C |
| 2A300 | 2 | 300 | 18 | 0 | (Fe, Fe ₃ C), Fe ₄ C |
| 2A320 | 2 | 320 | 15 | 7 | (Fe), Fe ₃ C, Fe ₄ N |
| 2A350 | 2 | 350 | 17 | 7 | (Fe), Fe ₃ C, Fe ₄ N |
| 2B280 | 2 | 280 | 12 | 9 | (Fe, Fe ₃ C), Fe ₄ N |
| 2B300 | 2 | 300 | 19 | 7 | (Fe), Fe ₃ C, Fe ₄ N |

Fig. 1. SEM-FEG micrograph of the film deposited from compound **2** at 350°C.

